

DECEMBER 2000

Registered in U.S. Patent and Trademark Office; Copyright 2000 by the American Chemical Society

COMMENTARY

Conformations of Linear Chains. Systematics and Suggestions for Nomenclature

ABSTRACT

There are six categories of calculated favored dihedral angles in linear MnX2n+2 chains. The Prelog-Klyne nomenclature is not helpful for classifying them, and we propose the following labels and symbols: A, anti, reserved for torsional angles within a few degrees of 180°; T, transoid, $\omega \approx 165^{\circ}$; D, deviant, $\omega \approx 150^{\circ}$; O, ortho, $\omega \simeq 90^{\circ}$; G, gauche, $\omega \simeq 60^{\circ}$; C, cisoid, $\omega \simeq 40^{\circ}$. With the exception of C, all of these categories have been observed in alkanes, perfluoroalkanes, or oligosilanes.

In introductory organic chemistry texts, conformational minima are described for *n*-butane. The preferred torsional angles ω are 180° (anti, A) and $\sim \pm 60^{\circ}$ (gauche, G).¹ These minima are due to the existence of intrinsic rotational barriers around single bonds, present even in ethane.² This simple and generally recognized situation applies when the lateral substituents on a linear chain are very small, e.g., in *n*-alkanes and oligosilanes, as observed³ in polyethylene and calculated⁴ for polysilane, $(SiH_2)_n$, but it has recently become clear that it is not general for $M_n X_{2n+2}$ chains.^{5,6}

In very severely crowded chains (e.g., X = tert-butyl⁷), in those in which some backbone valence angles are smaller than tetrahedral (e.g., thioethers⁸), and in other more complex cases, deviations from the usual 180° and $\pm 60^{\circ}$ angles are frequent, and the Prelog-Klyne nomenclature^{9,10} is then standard: $0^{\circ} < |\omega| < 30^{\circ}$, syn-periplanar (sp); $30^{\circ} < |\omega| <$ 90°, synclinal (sc); 90° < $|\omega|$ < 150°, anticlinal (ac); 150° < $|\omega| < 180^\circ$, antiperiplanar (ap). Potential energy minima at the borderline values, $|\omega| = \sim 90^{\circ}$ and $\sim 150^{\circ}$, are unfortunately common in $M_n X_{2n+2}$ chains with substituents X larger than H, making this notation unhelpful. This has contributed to a proliferation of symbols and notation for the conformations of polysilanes, Si_nX_{2n+2} . The purpose of this comment



of favored dihedral angles in $M_n X_{2n+2}$ chains with $X \neq H$, such as perfluoroalkanes and polysilanes, and to suggest a set of labels that preserves as much as possible of the current usage (we recognize that our list may not exhaust future intermediate conformations).

0°

30°

G+

60°

90°

-30°

G_

-60

С

As the size of the substituents X in an oligomeric or polymeric linear chain $(MX_2)_n$ is increased relative to the M–M bond length, repulsive interactions between X atoms in backbone positions 1 and 3 become important. It has long been recognized¹¹ that the exactly planar A geometry then becomes a transition state between two minima with $\omega \simeq$ $\pm 165^{\circ}$. In (MX₂)_n chains, these structures have been calculated for permethylated oligosilanes¹² and observed for perfluorinated polyethylene,¹³ which has two crystalline forms with $\omega \simeq 166^{\circ}$ and 168° . We will term these conformations transoid, T.

Similar interactions between groups X located in backbone positions 1 and 4 lead to a splitting of the gauche states into minima with $\omega \simeq \pm 55^{\circ}$ (G) and $\sim \pm 90^{\circ}$ (ortho, O).^{14,15} Until recently there has been little experimental evidence for the O conformation in $M_n X_{2n+2}$ chains,¹⁶ but it has now been observed directly in $C_4 F_{10}$ ¹⁷ and $Si_4 Cl_{10}$,¹⁸ and is also calculated to exist in $C_4 Me_{10}$, $Si_4 Me_{10}$, and $Si_4 (SiH_3)_{10}$.⁵

For longer alkyl substituents X, the situation becomes even more complicated.¹⁹ Now, not only the CH₂ group next to the backbone, but also the neighboring one may be involved in interactions between substituents. As a result, for particular local conformations of the alkyl substituents, in molecules such as Me₃Si–SiEt₂–SiEt₂–SiMe₃ certain T and G minima are calculated to disappear, and in their place appear new conformations with greatly reduced dihedral angles. For these, we have proposed⁶ the labels *deviant*²⁰ (D, $\omega \approx 150^{\circ}$) and *cisoid*²¹ (C, $\omega \approx 40^{\circ}$). The crystalline polymers [(*n*butyl)₂Si]_n and [(*n*-pentyl)₂Si]_n are known to adopt a helical conformation with $\omega \approx \pm 154^{\circ}$ (approximately a 7/3 helix),²² which we identify as D, but no observations of the C conformation have been reported so far.

For many polymers, the distinction between A, T, and D, or O, G, and C conformations may seem unimportant, because easily observed polymer properties other than the crystal structure may not depend greatly on the backbone conformation. It is known from experiments²³ and calculations²⁴ that the $\sigma - \sigma^*$ excitation energy depends strongly on the backbone conformation, but many saturated polymers absorb only in the vacuum UV, and little is known about their electronic spectra. However, polysilanes, polygermanes, and polystannanes absorb in the near-UV region. Their readily observable first $\sigma - \sigma^*$ absorption peak shifts dramatically to the blue as the backbone dihedral angle ω is reduced from 180° to smaller values, and this is easily understood in simple terms.²⁵ The existence of A, T, and D bond conformations, and of conformations involving mixtures of these rotational states, probably explains the multiplicity of ordered phases with differing UV maxima, observed recently for several polysilanes.^{26,27}

Listed in Figure 1 is the entire array of presently recognized, permitted rotational minima and the symbols which we suggest for use in describing these conformations: A, anti, reserved for torsional angles within a few degrees of 180°; T, transoid, $\omega \approx 165^{\circ}$; D, deviant, $\omega \approx 150^{\circ}$; O, ortho, $\omega \approx 90^{\circ}$; G, gauche, $\omega \approx 60^{\circ}$; C, cisoid, $\omega \approx 40^{\circ}$. With the exception of the planar A conformer, these backbone conformations are all chiral and appear as enantiomeric pairs. If the members of the pairs need to be referred to individually, we recommend notation such as T₊ (right-handed helix, $\omega \approx +165^{\circ}$) and T₋ (left-handed helix, $\omega \approx -165^{\circ}$).

The dark segments in Figure 1 indicate that bond eclipsing does not occur in stable conformers of linear chains. In certain constrained systems it is observed, however, and we propose the labels S, syn, for $\omega \simeq 0^{\circ}$ and E, eclipsed, for $\omega \simeq 120^{\circ}$.

References

- (1) Lowercase letters have often been used in the literature to represent conformations, but we will use uppercase letters throughout for the backbone.
- (2) Of the various rationalizations of their origin that have been proposed, we favor the one that invokes σ conjugation: Reed, A. E.; Weinhold, F. Natural Bond Orbital Analysis of Internal Rotational Barriers and Related Phenomena. *Isr. J. Chem.* **1991**, *31*, 277–285.
- (3) Seto, T.; Hara, T.; Tanaka, T. Phase Transformation and Deformation Processes in Oriented Polyethylene. *Jpn. J. Appl. Phys.* **1968**, 7, 31–42. Oyama, T.; Shiohara, K.; Ishimaru, T. Chain Conformation on the Surface of Polyethylene Single Crystals. *J. Macromol. Sci.*—Phys. **1973**, *B8*, 229–239.

- (4) Teramae, T.; Takeda, K. Ab Initio Studies on Silicon Compounds. 2. On the Gauche Structure of the Parent Polysilane. J. Am. Chem. Soc. 1989, 111, 1281–1285. Suhai, S. Third-Order Moeller–Plesset Theory of Electron Correlation in Infinite Systems: A Comparison of Carbon- and Silicon-based Polymers. Int. J. Quantum Chem., Quantum Chem. Symp. 1993, 27, 131–146.
- (5) Neumann, F.; Teramae, H.; Downing, J. W.; Michl, J. Gauche, Ortho, and Anti Conformations of Saturated A₄X₁₀ Chains: When Will all Six Conformers Exist? *J. Am. Chem. Soc.* **1998**, *120*, 573– 582.
- (6) Michl, J.; West, R. Electronic Structure and Spectroscopy of Polysilanes. In *Silicon-Containing Polymers: The Science and Technology of their Synthesis and Applications*; Jones, R. G., Ando, W., Chojnowski, J., Eds.; Kluwer Academic Publishers: Dordrecht, The Netherlands, 2000; pp 499–529.
- (7) For a leading reference, see: Baxter, S. G.; Fritz, H.; Hellmann, G.; Kitschke, B.; Lindner, H. J.; Mislow, K.; Ruechardt, C.; Weiner, S. Conformational Analysis of 1,1,2,2-tetracyclohexylethane. *J. Am. Chem. Soc.* **1979**, *101*, 4493–4497.
- (8) Allinger, N.; Hickey, M. J. Conformational Analysis. CVIII. Calculation of the Structures and Energies of Alkanethiols and Thiaalkanes by the Molecular Mechanics Method. J. Am. Chem. Soc. 1975, 97, 5167–5177.
- (9) Prelog, W.; Klyne, V. Description of Steric Relationships Across Single Bonds. *Experientia* 1960, 16, 521–523. Eliel, E. L.; Wilen, S. H.; Mander, L. N. *Stereochemistry of Organic Compounds*; Wiley: New York, 1994; p 21.
- (10) (a) Moss, G. P. Basic Terminology of Stereochemistry. *Pure Appl. Chem.* **1996**, *68*, 2193–2222. (b) Stereochemical Definitions and Notations Relating to Polymers. *Pure Appl. Chem.* **1981**, *51*, 733–752.
- (11) Boyd, R. H.; Phillips, P. J. *The Science of Polymer Molecules*; Cambridge University Press: Cambridge, 1993.
- (12) Albinsson, B.; Teramae, H.; Downing, J. W.; Michl, J. Conformers of Saturated Chains: Matrix Isolation, Structure, IR and UV Spectra of *n*-Si₄Me₁₀. *Chem. Eur. J.* **1996**, *2*, 529–538. Albinsson, B.; Antic, D.; Neumann, F.; Michl, J. The Conformers of *n*-Si₅Me₁₂: A Comparison of Ab Initio and Molecular Mechanics Methods. *J. Phys. Chem. A* **1999**, *103*, 2184–2196. Ottosson, C. H.; Michl, J. Conformers of *n*-Si₆Me₁₄: Ab Initio, Molecular Mechanics, and Additive Increment Methods. *J. Phys. Chem. A* **2000**, *104*, 3367–3380.
- (13) Yamamoto, T.; Hara, T. X-ray Diffraction Study of Crystal Transformation and Molecular Disorder in Poly(tetrafluoroethylene). *Polymer* 1981, 22, 1475–1480. Weeks, J. J.; Clark, E. S.; Eby, R. K. Crystal Structure of the Low Temperature Phase of Polytetrafluoroethylene. *Polymer* 1981, 22, 1480–1486.
- (14) Teramae, H.; Michl, J. Electronic States of Linear Tetrasilane and Polysilanes. *Mol. Cryst. Liq. Cryst.* **1994**, *256*, 149–159.
- (15) Smith, G. D.; Jaffe, R. L.; Yoon, D. Y. Configurational Characteristics of Poly(tetrafluoroethylene) Chains Based Upon Ab Initio Electronic Structure Calculations of Model Molecules. *Macromolecules* 1994, *27*, 3166–3173.
- (16) For an early example, see: Shafiee, F.; Haller, K. J.; West, R. X-ray Crystal and Molecular Structures of Hexacosamethylcyclotridecasilane, (Me₂Si)₁₃, and Dodecatriacontamethylcyclohexadecasilane, (Me₂Si)₁₆. J. Am. Chem. Soc. **1986**, 108, 5478–5482.
- (17) Albinsson, B.; Michl, J. The Anti, Ortho, and Gauche Conformers of Perfluoro-*n*-Butane: Matrix-Isolation IR Spectra and Calculations. J. Phys. Chem. **1996**, 100, 3418–3429.
- (18) Zink, R.; Magnera, T. F.; Michl, J. The Transoid, Ortho and Gauche Conformers of n-Si₄Cl₁₀: Raman and Mid-IR Matrix-Isolation Spectra. J. Phys. Chem. A 2000, 104, 3829–3841.
- (19) Farmer, B. L.; Rabolt, J. F.; Miller, R. D. Conformational Calculations on Poly(di-*n*-hexylsilane). *Macromolecules* **1987**, *20*, 1167– 1169. Fogarty, H. A.; Ottosson, C. H.; Michl, J. The Five Favored Backbone Conformations of *n*-Si₄Et₁₀: Cisoid, Gauche, Ortho, Deviant, and Transoid. *J. Mol. Struct. (Theochem)* **2000**, *506*, 243– 255. Fogarty, H. A.; Ottosson, C. H.; Michl, J. Conformations of Oligosilanes with Ethyl and Methyl Substituents, *J. Mol. Struct.*, in press.
- (20) We have agonized considerably over the choice of this name but have come up with no better choice that starts with the letter D, already established in a fair number of published articles. Besides, a conformation with $|\omega| = \sim 150^{\circ}$ would, indeed, appear to be somewhat of a miscreant.
- (21) This term has also been used to describe the s-cis conformation of 1,3-dienes, but this usage is discouraged by IUPAC,^{10a} and there should be no danger of confusion.
- (22) Miller, R. D.; Farmer, B. L.; Fleming, W.; Sooriyakumaran, R.; Rabolt, J. Poly(di-n-pentylsilane): The Spectral Consequences of a Helical Conformation in the Solid State. J. Am. Chem. Soc. 1987,

109, 2509–2510. Schilling, F. C.; Lovinger, A. J.; Zeigler, J. M.; Davis, D. D.; Bovey, F. A. Electronic Absorption and Structural Properties of Poly(di-*n*-butylsilylene) Precipitated from Solution at Low Temperature. *Macromolecules* **1990**, *23*, 1742–1746.

- (23) Imhof, R.; Teramae, H.; Michl, J. Conformational Effects in UV Absorption Spectra of Tetrasilanes. *Chem. Phys. Lett.* **1997**, *270*, 500–505.
- (24) Mintmire, J. W. Conformational Effects in Organopolysilanes—A First Principles Approach. *Phys. Rev. B* **1989**, *39*, 13350–13357. Crespo, R.; Teramae, H.; Antic, D.; Michl, J. Calculation of the Conformational Dependence of Valence and Rydberg States in *n*-Tetrasilane. *Chem. Phys.* **1999**, *244*, 203–214.
- (25) Klingensmith, K. A.; Downing, J. W.; Miller, R. D.; Michl, J. Electronic Excitation in Poly(di-*n*-hexylsilane). *J. Am. Chem. Soc.* **1986**, *108*, 7438–7439. Plitt, H. S.; Michl, J. Conformational Effects on *a*-Conjugation: UV and IR Spectra of Matrix Isolated *trans*-and *gauche-n*-Si₄Me₁₀. *Chem. Phys. Lett.* **1992**, *198*, 400–405. Plitt, H. S.; Downing, J. W.; Raymond, M. K.; Balaji, V.; Michl, J. Photophysics and Potential Energy Hypersurfaces of Permeth-ylated Oligosilanes. *J. Chem. Soc., Faraday Trans.* **1994**, *90*, 1653–1662.
- (26) Bukalov, S. S.; Leites, L. A.; West, R.; Asuke, T. A Detailed UV and Raman Study of Poly(*n*-butyl-*n*-hexylsilylene) Phase Transitions. *Macromolecules* **1996**, *19*, 907–912.
- (27) Chunwachirasiri, W.; West, R.; Winokur, M. J. New Models for Rotational States and their Application to Polysilanes. *Macro-molecules*, in press. Mueller, C.; Frey, H.; Schmidt, C. Phase Behaviour of Poly(di-*n*-decylsilylene). *Monatsh. Chem.* **1999**, *130*, 175–180.

JOSEF MICHL*

Department of Chemistry and Biochemistry University of Colorado, Boulder, Colorado 80309-0215

ROBERT WEST

Department of Chemistry

University of Wisconsin, Madison, Wisconsin 53706-1396

AR0001057